

Formelsammlung

Elektronische Bauelemente

Die meisten Formeln/Zusammenhänge sind dem Buch zur Vorlesung „Elektronische Bauelemente“ von Prof. Dr. rer. nat. Klaus Heime entnommen. Hinter den einzelnen Formeln wird deshalb auf die jeweiligen Seiten im Buch verwiesen.

Diese Formelsammlung wurde 1993 erstellt und seit dem nicht aktualisiert. Nach einer Anfrage im September 2001 habe ich nun die Umlaute angepaßt, Anpassungen an L^AT_EX2e durchgeführt, meine eMail-Adresse korrigiert und die Formelsammlung inkl. L^AT_EX-Quellcode ins WWW gestellt. Dort ist sie unter der Adresse <http://www.oche.de/leutloff/elektrotechnik/> abrufbar.

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Letzte Änderung am 15.12.93.

Alle Angaben ohne Gewähr!

1 Potentialstufe und Potentialbarriere

Potentialstufe Transmissionsfaktor $E < V_0$ $E > V_0$ Reflexionsfaktor	$T = 0 \quad \text{und damit} \quad R = 1$ $T = \frac{4k_{II}}{k_I(1 + \frac{k_{II}}{k_I})^2} \quad (2.46)$ $\text{mit } k_I = \sqrt{\frac{2mE}{\hbar^2}} \quad \text{und} \quad k_{II} = \sqrt{\frac{2m(E - V_0)}{\hbar^2}} \quad (2.42)$ $R = 1 - T \quad (2.45)$	
Potentialbarriere (Breite a) Transmissionsfaktor $E < V_0$ (Tunneleffekt) $E > V_0$ Reflektionsfaktor	$T = \left[1 + \frac{\sinh^2 \left(\frac{a}{\hbar} \sqrt{2m(V_0 - E)} \right)}{4E(V_0 - E)} \right]^{-1} \quad (2.55)$ $T = \left[1 + \frac{\sinh^2 \left(\frac{a}{\hbar} \sqrt{2m(E - V_0)} \right)}{4E(E - V_0)} \right]^{-1} \quad (2.55)$ $R = 1 - T$	
Antreffwahrscheinlichkeit/Eindringtiefe (langer Stab)	$\frac{dE(x)}{dx} \approx e^{-2k_{II}x} \quad \text{mit} \quad k_{II} = \sqrt{\frac{2m(E - V_0)}{\hbar^2}}$ $\Rightarrow \text{Eindringtiefe } x_E = \frac{1}{2k_{II}}$	
DE BROGLIE-Wellenlänge	$\lambda = \frac{h}{\sqrt{2mE}} \quad (2.47)$ (2.130)	

2 Bändermodell für in- und extrinsische Halbleiter

(für intrinsische Halbleiter wird E_F durch E_{Fi} ersetzt)

n(T) 3.84

Besetzungswahrscheinlichkeit	$f(E) = \frac{1}{1 + e^{\frac{E-E_F}{kT}}}$	(3.27)
effektive Zustandsdichten	$N_L = 2 \left(\frac{2\pi m_n^* kT}{h^2} \right)^{\frac{3}{2}} \quad N_V = 2 \left(\frac{2\pi m_p^* kT}{h^2} \right)^{\frac{3}{2}}$	(3.44) (3.47) (3.75)
Konzentration	davon besetzt: $n = N_L e^{-\frac{E_L-E_F}{kT}} \quad p = N_V e^{-\frac{E_F-E_V}{kT}}$	
	$N_V = N_L \left(\frac{m_p^*}{m_n^*} \right)^{\frac{3}{2}} \quad \frac{E_g}{2} = E_{Fi} - E_V$	
Konzentration der Teilchen im Reservereich eines extrinsischen Halbleiters (Aktivierungsenergie: ΔE_D , ΔE_A)	$n = \sqrt{N_D N_L} e^{-\frac{\Delta E_D}{2kT}} \quad p = \sqrt{N_A N_L} e^{-\frac{\Delta E_A}{2kT}}$	(3.83)
Massenwirkungsgesetz	$n_i^2 = np = N_L N_V e^{-\frac{E_L-E_V}{kT}}$ $E_L = E_V + E_g$ im intrinsischen Halbleiter ist $n = p = n_i$	(3.47) (3.75)
Fermi-Niveau im intrinsischen Halbleiter	$E_{Fi} = \underbrace{E_V + \frac{1}{2} E_g}_{E_{Fi}(T=0)} + \underbrace{\frac{3}{4} kT \ln \frac{m_p^*}{m_n^*}}_{\Delta E_{Fi}(T)}$	(3.49)
Ladungsbilanz im extrinsischen Halbleiter	$n + N_A^- = p + N_D^+ \quad (\text{Neutralitätsbedingung})$	
	$N_D^+ = N_D \left(1 - \frac{1}{1 + e^{\frac{E_D-E_F}{kT}}} \right)$ $N_A^- = N_A \left(\frac{1}{1 + e^{\frac{E_A-E_F}{kT}}} \right)$	(3.79)
	mit $N_D = N_D^0 + N_D^+$ und $N_A = N_A^0 + N_A^-$	

thermische Geschwindigkeit	$v_{th} = \sqrt{\frac{3kT}{m^*}} \quad E_{kin} = \frac{3}{2}kT$	(3.88)
Beweglichkeit	$\mu_n = \frac{q\tau_n}{m_n^*} \quad \mu_p = \frac{q\tau_p}{m_p^*}$	(3.93)
Leitfähigkeit	$\sigma = \kappa = q(n\mu_n + p\mu_p) \quad (\sigma = qn_i(\mu_n + \mu_p))$	(3.93)
Abstand der Bänder <div style="border: 1px solid black; padding: 5px; width: fit-content; margin: 10px auto;">PN-Übergang Diagramm 4.3</div>	$\eta_n = E_{Ln} - E_F = kT \ln \frac{N_L}{n_n}$ $\eta_p = E_F - E_{Vp} = kT \ln \frac{N_V}{p_p}$	(4.2) (7.81)
EINSTEINsche Beziehung und Diffusionskoeffizient	$D_n = \mu_n U_T \quad D_p = \mu_p U_T$ mit $U_T = \frac{kT}{q} = 25,9 \text{ mV bei } 300 \text{ K}$	(4.10)
	$\vec{S} = -D \text{ grad } n$	(4.8)
Austrittsarbeit	$[q\Phi_{Hl} = E_0 - E_F \quad \text{!!Vorsicht!! bitte nachlesen!!}]$	(6.6)
Volumenpotential	$q\Psi_b = E_F - E_{Fi}$	(6.6)
Oberflächenpotential	$\varphi_s = \frac{qN_A^-}{2\varepsilon_0\varepsilon_r} l^2 \quad (> 0 \text{ bei Verarmung eines p-Halbl.})$	(6.11)
	$l = \frac{N_S^+}{N_A^-}$	(6.12)
	$l = \underbrace{\sqrt{\frac{\varepsilon_0\varepsilon_r U_T}{qN_A^-}}}_{\text{Debye-Länge } L_{Dp}} \quad \sqrt{\frac{2q\varphi_s}{kT}}$	(6.18)

Jeder weiß:

Energieerhaltungssatz: $h\nu = q\Phi_m + E_{Kin}$

Driftgeschwindigkeit: $\vec{v}_{dn} = -\mu_n \vec{E}$; $\vec{v}_{dp} = \mu_p \vec{E}$ (3.93)

3 PN-Übergang

(Nicht alle Formeln gelten für den PIN-Übergang!)

Diffusionsspannung	$-qU_D = E_g - \eta_{p0} - \eta_{n0}$ $U_D = -U_T \ln \frac{N_A N_D}{n_i^2}$	(7.81) (7.91)
maximale Feldstärke	$E_{0max} = \frac{2U_D}{l_0}$ für $U = 0$	(7.89)
Ausdehnung der Raumladungszone im p-Gebiet	$l_p = \sqrt{\frac{2\varepsilon_0\varepsilon_r N_D}{qN_A(N_A + N_D)} (-U_D - U)}$ ¹	(7.93)
im n-Gebiet	$l_n = \sqrt{\frac{2\varepsilon_0\varepsilon_r N_A}{qN_D(N_A + N_D)} (-U_D - U)}$ ¹	(7.93)
Gesamtlänge <div style="border: 1px solid black; padding: 2px; display: inline-block;">Diffusionsschwänze 7.100</div>	$l = l_n - l_p = \sqrt{\frac{2\varepsilon_0\varepsilon_r}{q} \left(\frac{1}{N_A} + \frac{1}{N_D} \right) (-U_D - U)}$	(7.94) (7.87)
Ideale Schockleysche HL-Diode	$I_D = I_0 \left(e^{\frac{U_D}{U_T}} - 1 \right)$	(7.103) (7.113)
Kennlinie	$I_{Du} = I_0 e^{\frac{U_D}{U_T}}$ ($U \gg U_T$) $I_{Sp} = -I_0$ ($U \ll U_T$)	
Sättigungsströme Langbasisdiode ($w \gg l_p$ bzw. l_n)	$I_{0Langb.} = qAU_T n_i^2 \left(\underbrace{\frac{\mu_p}{l_p N_D}}_{\text{Löcher}} + \underbrace{\frac{\mu_n}{l_n N_A}}_{\text{Elektronen}} \right)$	(7.104)
Kurzbasisdiode ($w \ll l_p$ bzw. l_n) (Sperrstrom $\sim \frac{1}{w}$)	$I_{0Kurz.} = qAU_T n_i^2 \left(\underbrace{\frac{\mu_p}{(l_1 - l_n) N_D}}_{\text{Löcher}} + \underbrace{\frac{\mu_n}{(l_2 - l_p) N_A}}_{\text{Elektronen}} \right)$	(7.104)
Temperaturabhängigkeit	$d_T = \frac{\Delta U}{\Delta T} = \alpha_T \frac{kT_0}{q}$ mit $\alpha_T = \frac{E_g}{kT_0^2}$	(7.106)
Raumladungskapazität (pro Einheitsfläche) Heteroübergang (Homoübergang folgt aus $\varepsilon_{r1} = \varepsilon_{r2}$)	$c_R = \sqrt{\frac{q\varepsilon_0\varepsilon_{r1}\varepsilon_{r2}N_A N_D}{2(\varepsilon_{r1}N_D + \varepsilon_{r2}N_A)} \frac{1}{-U_D - U}}$	(7.158) (7.108)

Bänder PN 7.79, PIN 7.133 ($U \neq 0!$) C/U-Diagr. 7.47 Kennl.: Tunnel 7.122; Backward 7.127

¹Bei $N_D \gg N_A$ kann bei $l_p N_D$ gegen $(N_D + N_A)$ gekürzt werden. Ähnliches gilt bei l_n , wenn $N_A \gg N_D$.

4 Bipolartransistor

Ersatzschaltbilder 12.6

Stromverstärkung	$A_N = \frac{I_{EC}}{I_{EE}} = \beta\gamma_E$	(9.38)
Transportfaktor	$\beta = \frac{1}{\cosh \frac{w}{L_n}} \quad (\beta \rightarrow 1 \text{ für } w \ll L_n)$	(9.38)
Emitterwirkungsgrad (vgl. Diode, I_0)	$\begin{aligned} \gamma_E &= \frac{\text{Elektronenstrom}}{\text{Elektronen- und Löcherstrom}} \\ &= \frac{1}{1 + \frac{\mu_{pE} N_A L_n}{\mu_{nB} N_{DE} l_{nE}} \tanh \frac{w}{L_n}} \end{aligned}$	(9.38)
Stromverstärkung der Emitterschaltung	$B_N = \frac{A_N}{1 - A_N}$	(9.32)
Kollektorstrom	$I_C = \frac{AqD_n n_p}{w_{B_{eff}}} \quad (\text{NPN-BipT})$ gilt nur, wenn die Rekombination in der Basis vernachlässigt werden kann	
Dichte der Minoritäten in der Basis	$n_p = n_{p0} e^{\frac{U_{BE}}{U_T}} \quad (\text{NPN-BipT})$	
Steilheit	$S = \left. \frac{\Delta I_C}{\Delta U_{BE}} \right _{U_{CE}=\text{const.}}$	
Leitwert	$g_{CE} = \left. \frac{\Delta I_C}{\Delta U_{CE}} \right _{U_{BE}=\text{const.}}$	

Ladungsträgerkonzentration 9.9/9.10
 Strom-Spannungskennlinien (Ebers-Moll-Gleichungen) 9.16
 Minoritätenkonzentration in der Basis (Diffusionsdreiecke) 9.18/9.20
 Admittanzen und Grenzfrequenzen in Kapitel 11

5 Schottky-Diode (Metall-Halbleiter-Kontakt)

Diffusionspannung <div style="border: 1px solid black; padding: 2px; display: inline-block;">Bändermodell 7.34</div>	$U_D = \frac{\eta_n}{q} - \Phi_{Bn} \quad \text{mit} \quad \Phi_{Bn} = \Phi_M - \chi \quad (7.35)$	
Ausdehnung der Raumladungszone	$l = \sqrt{\frac{2\varepsilon_0\varepsilon_r H l}{q N_D^+} (-U_D - U)} \quad (U \leq -U_D) \quad (7.45)$	
Kennlinie	$I_{Du} = I_0 \left(e^{\frac{U}{U_T}} - 1 \right) \quad (U \geq 0) \quad (7.56)$	
	$I_{Sp} = I_0 \left(1 - e^{\frac{U}{U_T}} \right) \quad (U \leq 0) \quad (7.58)$	
mit Berücksichtigung des Bahnwiderstandes	$I = I_0 \left(e^{\frac{U - I R_B}{U_T}} - 1 \right) \quad (U \geq 0) \quad (7.65)$	
Sättigungsstrom nach der Diodentheorie ($mfw \gg 1$)	$I_0 = F \frac{m^*}{m_0} A T^2 e^{-\frac{q\Phi_{Bn}}{kT}} \quad (7.56)$	
nach der Diffusionstheorie ($mfw \ll 1$)	mit Richardson-Konst. $A = 120 \frac{\text{A}}{\text{cm}^2 \text{K}^2}$ und F dem stromdurchflossenen Querschnitt	
	$I_0 = F q v_d n_R \quad (7.58)$	
	mit $\vec{v}_d = \mu_n \vec{E}_R$ (Randfeldstärke)	
	und $n_R = N_L e^{-\frac{q\Phi_{Bn}}{kT}}$ (Elektronenkonz. am Rand)	(7.55)
Verhalten der Diode für sehr kleine Spannungen (Näherung)	$R = \frac{U_T}{I_0} \quad \text{für} \quad U \leq 10\text{mV} \quad (7.65)$	
Temperaturabhängigkeit	$I_0(T_0 + \Delta T) = I_0(T_0) e^{\alpha_T \Delta T} \quad \text{mit} \quad \alpha_T = \frac{q\Phi_{Bn}}{kT_0^2} = \frac{a}{T_0^2} \quad (7.67)$	
Temperaturdurchgriff	$d_T = \frac{\Delta U}{\Delta T} = \alpha_T \frac{kT_0}{q} \quad (7.71)$	
Raumladungskapazität (pro Einheitsfläche)	$c_R = \sqrt{\frac{q\varepsilon_0\varepsilon_r H l N_D^+}{2} \frac{1}{-U_D - U}} \quad (U \leq -U_D) \quad (7.45)$	

6 MIS-Struktur bzw. MOS-Struktur

Flachbandspannung	$U_{FB} = \underbrace{\Phi_{MHI}}_{\text{Differenz der Austrittsarbeit}} - \underbrace{\frac{Q_{Is}}{C_{Is}}}_{\text{negative Oxidladung}} - \underbrace{\frac{Q_{ss}}{C_{Is}}}_{\text{Oberflächenzustände}} \quad (7.17)$	
Ausdehnung der Raumladungszone im n-Halbleiter (gleich Schottky-Kontakt, wenn $-U_D$ durch U_{FB} ersetzt wird)	$l = \sqrt{\frac{2\varepsilon_0\varepsilon_r Hl}{qN_D^+} (U_{FB} - U)} \quad (U \leq U_{FB}) \quad (7.20)$	
(Raumladungs-)Kapazität der Diode für die Verarmung für Anreicherung und Inversion	$C_R = \sqrt{\frac{q\varepsilon_0\varepsilon_r Hl N_D^+}{2}} \frac{1}{U_{FB} - U} \quad (U \leq U_{FB}) \quad (7.21)$ $C_{Is} = \frac{\varepsilon_0\varepsilon_r I_s}{d_{Is}} \quad (7.18)$	

Ideale MIS-Struktur 7.5ff
 Reale MIS-Struktur 7.10ff
 C (U, f) 7.28

8 Halleffekt

Wichtigste Meßmethode zur Bestimmung der Beweglichkeiten im Halbleiter.

Hallspannung	$U_H = -vdB_z = R_H \frac{I_x B_z}{w}$	(4.14)
Hallkonstante für n-Halbleiter im extr. Ber.	$R_H = -\frac{1}{nq}$	(4.14)
für p-Halbleiter im extr. Ber.	$R_H = +\frac{1}{pq}$	
für gemischte Halbleiter	$R_H = r \frac{p\mu_p^2 - n\mu_n^2}{q(p\mu_p + n\mu_n)^2}$	(4.15)
Widerstandseffekte 4.19–4.22	mit $r = \frac{3\pi}{8}$ wg. gekrümmter Bahnen; kann im Allgemeinen weggelassen werden ($r = 1$)	
	$\mu_n = -R_H \kappa_n$	(4.15)

9 Photoleitung

Photoleitfähigkeit	$\kappa_{Ph} = q(\mu_n \Delta n + \mu_p \Delta p)$ mit $\Delta n = \Delta p$	(4.40)
stationärer Zustand	$\boxed{1} \quad \Delta n = n_1 = \sqrt{\frac{L}{B}} \quad \left[= \sqrt{\frac{L\eta}{B}} \right]$ <p> $L = \text{Generationsrate};$ $B = \text{Proportionalitätskonstante};$ $\eta = \text{Quantenwirkungsgrad}$ </p> $\boxed{2} \quad \Delta n = n_1 = L\tau_n$ <p> $\tau_n = \frac{1}{C} = \text{Lebensdauer der Elektronen}$ </p>	(4.36)
Anklingen nach Einschalten	$\Delta n = Lt$	(4.36)
Abklingen nach Abschalten (bei $t = t_1$)	$\boxed{1} \quad \Delta n = \frac{\Delta n_1}{1 + \Delta n_1 B(t - t_1)}$ $\boxed{2} \quad \Delta n = \Delta n_1 e^{-\frac{t-t_1}{\tau_n}} \quad \Delta n_1 = n_1$	(4.38)
Verstärkungsfaktor	$v = \frac{\Delta n v_n}{Ll} = \frac{\tau}{T_d}$ mit $T_d = \frac{l}{v_n} = \frac{l^2}{\mu_n U}$	(4.42)

- $\boxed{1}$ Elektronen im Leitungsband rekombinieren nur mit Löchern im Valenzband
 $\boxed{2}$ viele Rekombinationsmöglichkeiten

und weiter gehts ...

Lichtabsorption im Halbleiter	<p style="text-align: center;">Lichtintensität $I(x) = I_0 e^{-\alpha x}$ (5.1)</p> <p style="text-align: center;">Absorption \sim Störstellenkonzentration (5.9)</p>	
Laser-Bedingung	<p style="text-align: center;">$g > \frac{1}{L} \ln \frac{1}{R} + \alpha$ (5.29)</p> <p style="text-align: center;">$R = \text{Reflexionsvermögen} \approx \frac{(1 - \bar{n})^2}{(1 + \bar{n})^2}$ mit $\bar{n} = \sqrt{\epsilon_r}$ (5.26)</p>	
verfügbare Leistung einer Solarzelle <div style="border: 1px solid black; padding: 2px; display: inline-block;">Diagramm 7.134</div>	<p style="text-align: center;">$P_V = U_L I_L = F U_{L0} I_{K0}$ $U_{L0} \approx U_D$ $F = \text{Füllfaktor}$ (7.132)</p>	
Quantenenergie	<p style="text-align: center;">$E_{Ph} = h\nu = \frac{hc}{\lambda} = m_{Ph} c^2$ (2.5) (2.130)</p> <p style="text-align: center;">absorbierte Photonenenergie = Bandabstand E_g</p>	

10 Was weiß ich

„ switched capacitor “	$R = \frac{1}{Cf_C} \quad \text{mit} \quad f_C \gg f_{max}$	(10.9)
$V \times B$ - Produkt	$V \times B = \frac{S}{c_a} \quad c_a = \text{wirksame Kapazität am Ausgang}$	(12.34)

Neue Norm der Gattersymbole 13.4 und 13.7

11 Vermischtes zum Fragenteil

Bandabstand

↑↑	GaAs	höherer Bandabstand
	Si	→ geringere Eigenleitungsichte
	Ge	→ höhere Betriebstemperaturen

direkter Halbleiter Valenz- und Leitungsbandmaximum liegen im Impulsraum gegenüber
 → höhere Rekombinationsrate → kürzere Trägerlebensdauer

Durchbruchmechanismen (7.115):

Lawinendurchbruch mit zunehmender Temperatur kürzere freie Weglänge
 $(TK > 0; |U| > 5..6V)$
 → Durchbruchspannung steigt

Zenerdurchbruch mit zunehmender Temperatur größere Tunnelwahrscheinlichkeit
 $(TK < 0; |U| < 5..6V)$
 → Zenerspannung sinkt

thermischer Durchbruch

Bipolartransistor

Dotierung	↑↑	Emitter
		Basis
		Kollektor

wide-gap-Emitter (7.155, 7.137) größerer Bandabstand des Emitttermaterials (PN-Heteroübergang)
 → hohe Basisdotierung möglich
 → höher Emitterwirkungsgrad
 → verbesserte Hochfrequenzeigenschaften

FET mit steigender Temperatur sinkt die Ladungsträgerbeweglichkeit und die Sättigungsgeschwindigkeit im Kanal

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